

L Number	Hits	Search Text	DB	Time stamp
1	0	LINOX and anneal\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/03/18 13:34
2	2	LINOX	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/03/18 13:34
3	153087	(trench near\$3 oxide) and ((anneal\$3) or (thermal adj (treat\$3 or process\$3) or sinter\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/03/18 13:38
4	1574	((trench near\$3 oxide) and ((anneal\$3) or (thermal adj (treat\$3 or process\$3) or sinter\$3))) and (shallow adj trench) and (oxide) and anneal\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/03/18 14:20
5	337	((((trench near\$3 oxide) and ((anneal\$3) or (thermal adj (treat\$3 or process\$3) or sinter\$3))) and (shallow adj trench) and (oxide) and anneal\$3) and ((liner or barrier) adj (layer or film or coating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/03/18 14:22